

TECHNICAL DATA SHEET

High-tek coating DC

General notes:

» This coating is composed of carbon clusters (sp2-sp3 configuration) which develop an amorphous structure similar to a natural diamond and its related properties. The quota of the sp3-configured carbon lies at around 60-80%, which is the reason for the high values of hardness and abrasion resistance. This high-tech coating is done by a very innovative plasma-assisted high vacuum deposition technique. Furthermore, due to its procedure, the coating is completely free of hydrogen and oxygen.



High hardness (up to 50 GPa) and high elastic modulus (up to 350GPa)

High adhesion to the metallic substrate

Anthracite colour

Low thickness (1-2 microns)

Good elasticity



Extremely high wear and abrasion resistance (protects fine tip tweezers from wear)

No particulate shedding (no contamination of the handled components)



Chemically inert up to 350°C

High corrosion resistance

Bio-compatible (maintain cell integrity, no inflammatory response), no contamination of biological tissue with metal particles, nickel free

Not compatible with hydrogen peroxide-based solutions

Alcohol-resistant surface cleaning

Very clean material

NVR (Non Volatile Residue)
LPC 0.5 μm (Liquid Particle Count)
IC (Ion Chromatoghraphy)

0.088 μg/cm²
7043 counts/cm²
chloride 0.039 μg/cm²
nitrate not detected
sulfate 0.005 μg/cm²
total anions 0.114 μg/cm²



ESD safe coating

Surface Resistance

10⁴ ohm

Thisdocumentcontains information based on average values a sobtained from the results of laboratory tests and observations made on the material. Ideal-tek SA declines all responsibility from an improper use of the product described in this document.